

Small Signal Low Frequency MOS MODEL

Small Signal means amplitude of signal is very much smaller than (amplitude) or value of DC bias. $\forall$

i.e.
$$V_{GS} = V_{GS} + v_{gs}$$

$$V_{DS} = V_{DS} + v_{ds}$$

$$i_{DS} = i_{ds} + I_{DS}$$

For a MOSFET with small signal input at Gate (V_{GS}) we have

$$i_{DS} = I_{DS} + i_{ds} = \frac{\beta}{2} [(V_{GS} + v_{gs}) - V_{TH}]^2 (1 + \lambda V_{DS})$$



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Assuming $\lambda \rightarrow 0$

$$i_{DS} = \frac{\beta}{2} (V_{GS} - V_T)^2 + \frac{\beta}{2} (v_{gs})^2 + 2 \cdot \frac{\beta}{2} (V_{GS} - V_T) v_{gs}$$

For Small Signal case $v_{gs}^2 \rightarrow \text{Small} \rightarrow \text{Neglected}$

$$\therefore i_{DS} = I_{DS} + i_{ds}$$

$$= \frac{\beta}{2} (V_{GS} - V_T)^2 + \beta (V_{GS} - V_T) v_{gs}$$

$$\therefore i_{ds} = \beta (V_{GS} - V_T) v_{gs}$$

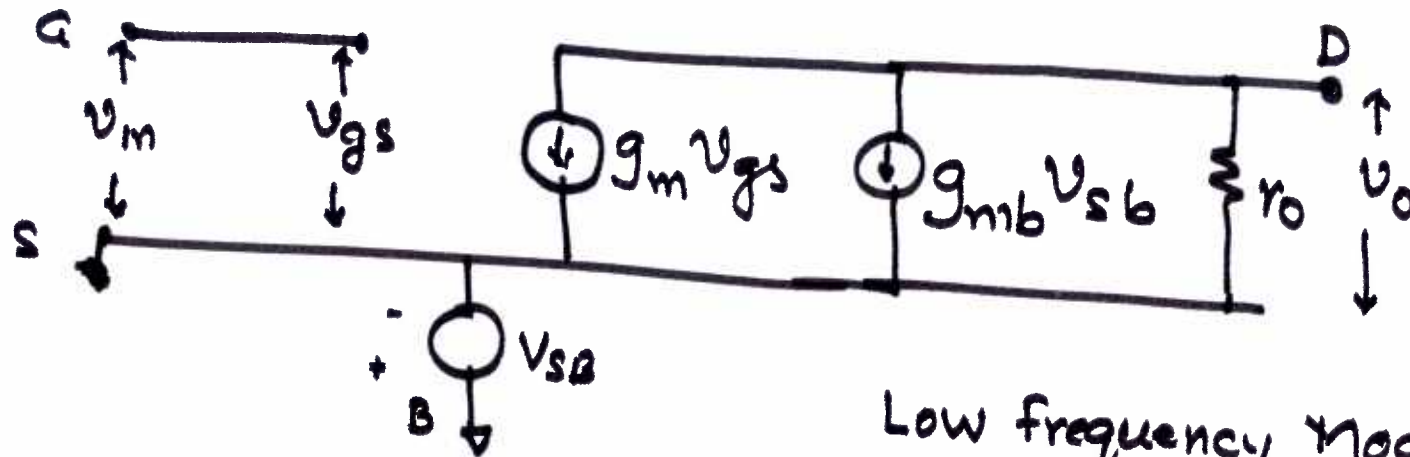
$$\frac{i_{ds}}{v_{gs}} = g_m = \beta (V_{GS} - V_T) = \frac{1}{2} \beta \frac{(V_{GS} - V_T)^2 \times 2}{(V_{GS} - V_T)} = \sqrt{2\beta I_{DS}}$$



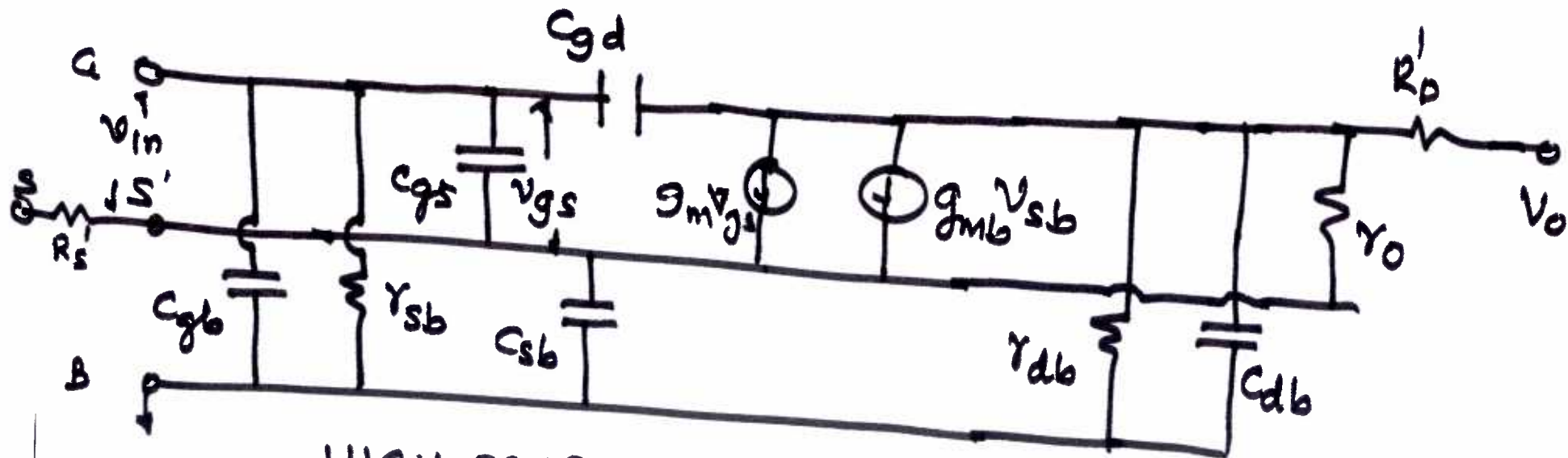
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Small Signal MODEL



Low frequency Model



HIGH FREQUENCY SMALL SIGNAL MOS MODEL

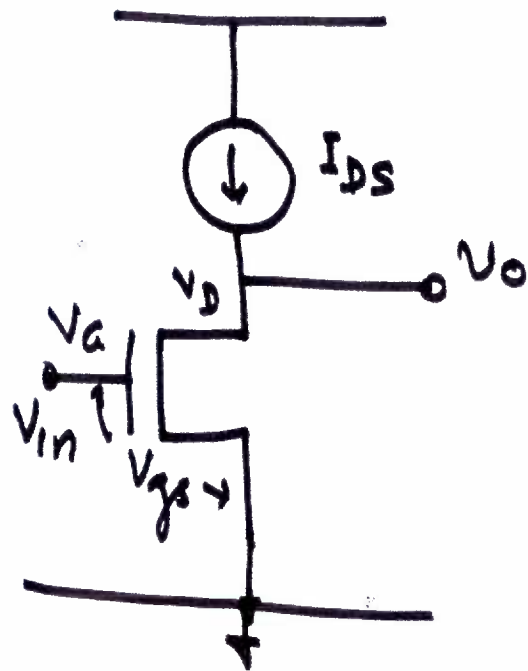


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Common Source Amplifier in an IC

Amplifier with constant
current Biasing (I_{DS} const.)



We have $I_{DS} = f(V_G \& V_D)$

$$\therefore \Delta I_{DS} = \frac{\partial I_{DS}}{\partial V_G} \cdot \Delta V_G + \frac{\partial I_{DS}}{\partial V_D} \cdot \Delta V_D$$

By definition

$$g_m = \frac{\partial I_{DS}}{\partial V_G} \quad \& \quad g_o = \frac{\partial I_{DS}}{\partial V_D}$$

$$\therefore \Delta I_{DS} = g_m \Delta V_G + g_o \Delta V_D$$

$$\text{or } dI_{DS} = g_m dV_G + g_o dV_D$$

$$\text{But } V_{in} = dV_G \quad \text{and} \quad V_o = dV_D$$



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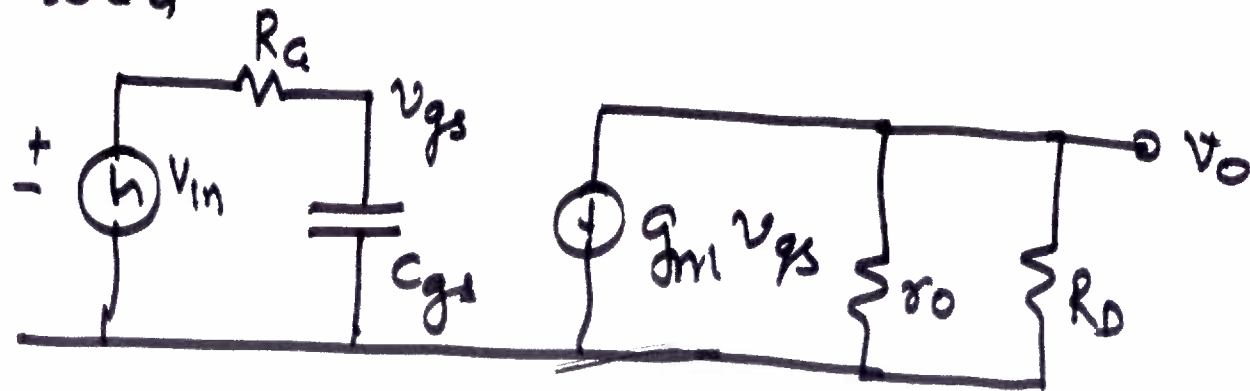
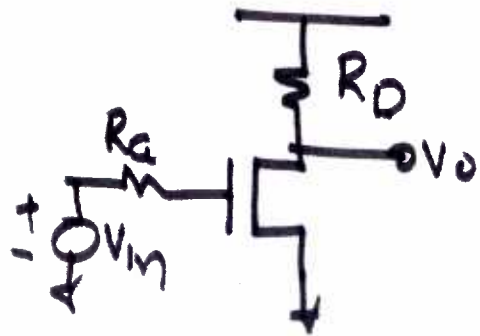
$$\therefore dI_{DS} = g_m v_{in} + g_o v_o$$

As Amplifier is biased by Constant Current Source I_{DS} , Hence $dI_{DS} = 0$

$$\therefore 0 = g_m v_{in} + g_o v_o$$

$$\therefore \frac{v_o}{v_{in}} = - \frac{g_m}{g_o} = - g_m r_o$$

If we take First Order Model of MOSFET with Resistive load



If $r_{od} = r_o$

Then $A_{vo} = -g_m r_o$ or $\left| \frac{r_o}{A_{vo}} \right| = \frac{1}{g_m}$

We can see that

$$\frac{g_m}{I_{Ds}} = \frac{2}{V_{ov}} \quad \& \quad \frac{g_m}{C_{gs}} = \frac{3}{2} \mu \frac{V_{ov}}{L^2}$$

Can be termed as Figures of Merit

Hence Major decision for any Analog Designer is to choose V_{ov} appropriately, so that

1. Power Dissipation
 - 2 Gain
 - & 3. Bandwidth
- specs are met



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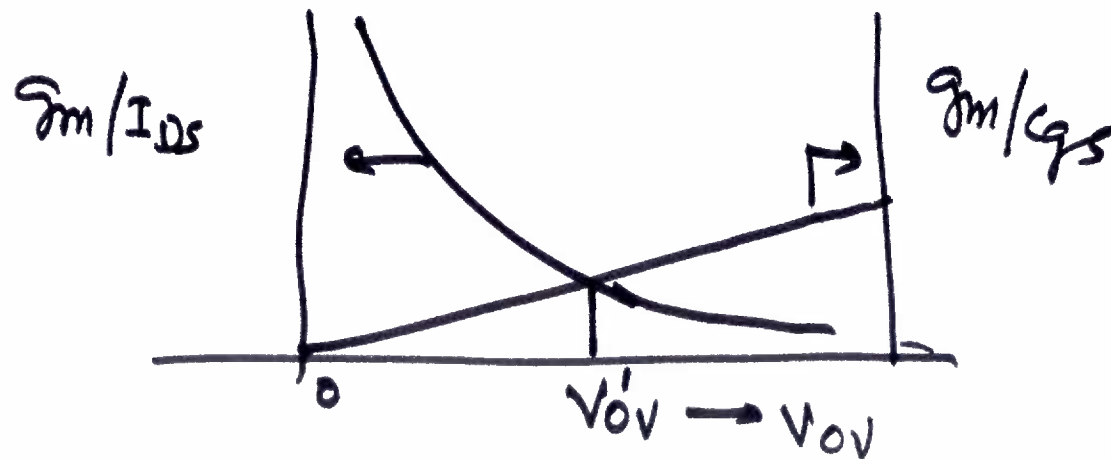
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We have observed that Performance of MOSFET ^{Amplifier} can be defined by two Figure of Merit, namely

$$\frac{g_m}{I_{D_S}} \quad \text{and} \quad \frac{g_m}{C_{gs}}$$

where

$$\frac{g_m}{I_{D_S}} = \frac{2}{V_{ov}} \quad \text{and} \quad \frac{g_m}{C_{gs}} = \frac{3}{2} \left(\frac{\mu}{L^2} \right) V_{ov}.$$



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Optimum value of $V_{ov} = V_{ov}'$ from Figure.

Hence Designer should make reasonable correct choice of V_{ov} .

Another Figure of Merit could be defined as Product-

$$FM_3 = \frac{g_m}{I_{DS}} \cdot \frac{g_m}{C_{gs}} = \frac{2}{V_{ov}} \cdot \frac{3}{2} \left(\frac{\mu}{L^2} \right) V_{ov}$$

$$= 3 \left(\frac{\mu}{L^2} \right)$$

Which is not a function of V_{ov} .

Hence to improve FM_3 , we must reduce Channel Length L .

FM_3 essentially represents
Think How about A_v ??

SPEED & POWER Efficiency together.



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Then

$$H(s) = \frac{v_o(s)}{v_{in}(s)} = -g_m(r_o \parallel R_D) \cdot \frac{1}{1 + s R_D C_{gs}}$$

We can use $g_m = \frac{2I_{DS}}{V_{OV}}$

$$C_{gs} = \frac{2}{3} W \cdot L C_{ox} \quad (\sim C_{ox})$$

$$\& \quad r_o = \frac{1}{\lambda I_{DS}}$$

$$\text{Then } A_v(s) = H(s) = A_{vo} \frac{1}{1 + s(R_D C_{gs})}$$

$$\begin{aligned} \text{where } A_{vo} &= -g_m(r_o \parallel R_D) = -g_m R_D \quad \text{if } R_D \ll r_o \\ &= g_m r_o \quad \text{if } R_D \gg r_o \end{aligned}$$

→ Say from Current Source



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From $A_v(s)$, we see we have a pole
at $\omega_0 = \frac{1}{R_C C_{gs}}$, which is therefore
the Bandwidth.

If we write $C_{gs} = \frac{2}{3} W L C_{ox}$

But $C_{ox} \mu \frac{W}{L} V_{ov} = g_m$

$$\therefore C_{ox} = g_m \left(\frac{L}{W} \right) (V_{ov})^{-1} \frac{1}{\mu}$$

$$C_{ox} = \frac{A_{vo}}{(r_{o1} || R_D)} \cdot \frac{L}{W} \cdot \frac{1}{V_{ov}} \cdot \frac{1}{\mu}$$

$$\therefore C_{gs} = \frac{2}{3} W L \cdot \frac{A_{vo}}{r_{od}} \left(\frac{L}{W} \right) \frac{1}{V_{ov}} \cdot \frac{1}{\mu}$$

$$\therefore \omega_0 = \frac{3}{2} \frac{r_{od}}{R_C} \cdot \frac{1}{A_{vo}} \frac{\mu}{L^2} V_{ov}$$

We define
 $r_{od} = r_{o1} || R_D$



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We see the Bandwidth

$$\omega_0 = \underbrace{\frac{3}{2} \cdot \frac{r_{od}}{R_a} \cdot \frac{1}{A_{vo}}}_{\text{Specs}} \cdot \underbrace{\frac{\mu}{L_2}}_{\text{Technology}} \cdot \underbrace{V_{ov}}_{\text{Design}} \quad \text{--- (1)}$$

We now evaluate Power Dissipation

$$\begin{aligned} P_D &= V_{DD} \cdot I_{DS} \\ &= \frac{1}{2} \frac{V_{DD}}{r_{od}} \cdot A_{vo} V_{ov}. \end{aligned} \quad \text{--- (2)}$$

From (1) & (2) we observe

P_D can be reduced by Reducing V_{ov}
But Reduction in V_{ov} reduces Bandwidth

We have

$$I_{Ds} = \frac{1}{2} \mu C_{ox} \left(\frac{W}{L} \right) V_{ov}^2$$

Also, we have $g_m = \frac{2I_{Ds}}{V_{ov}}$

$$\therefore \frac{W}{L} = \frac{g_m}{\mu C_{ox} V_{ov}}$$

$$\text{or } W = (g_m \cdot L) \left(\frac{1}{\mu} \right) \left(\frac{1}{C_{ox}} \right) \left(\frac{1}{V_{ov}} \right)$$

If we fix g_m & L , then for lower V_{ov}

We get larger W — width of the Transistor

But $C_{gs} = \frac{2}{3} W \cdot L \cdot C_{ox}$, will increase if W increases
Which will reduce Bandwidth.

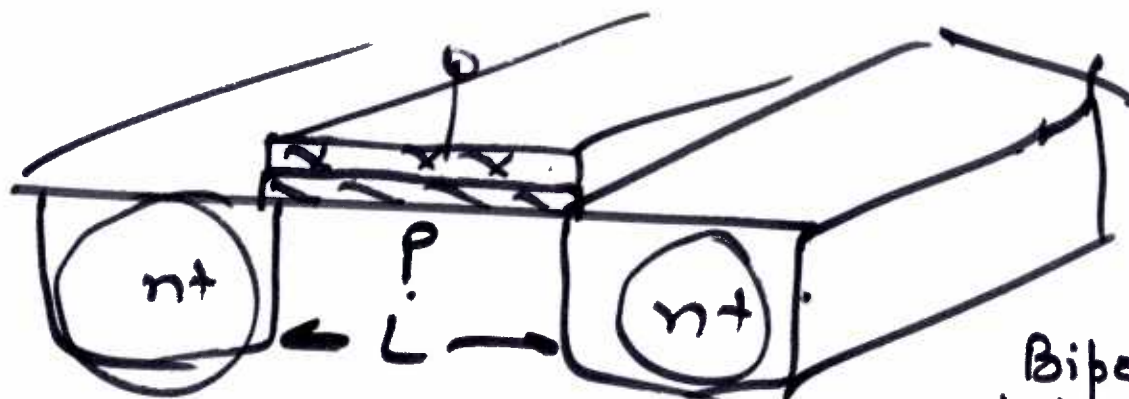


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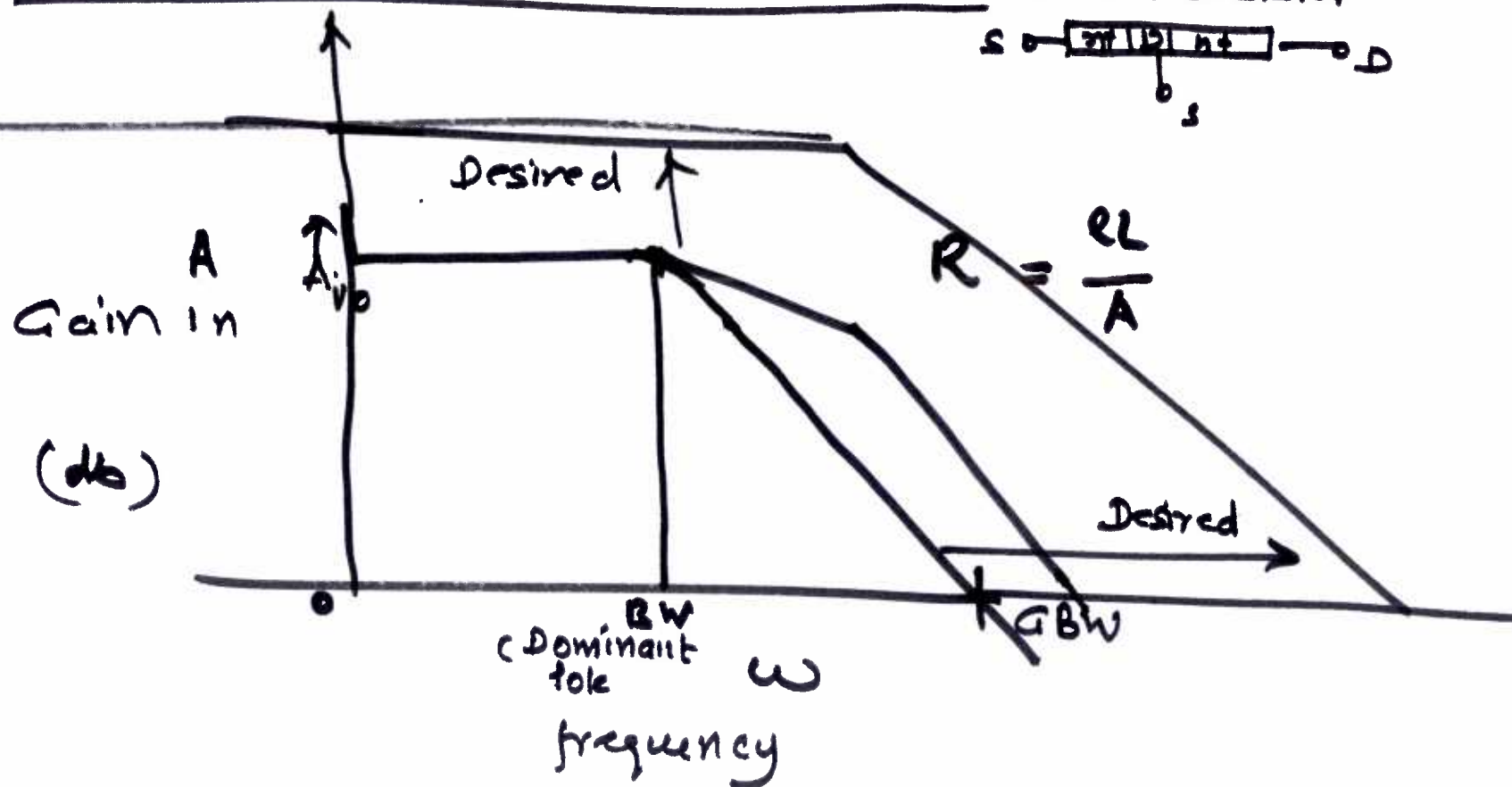


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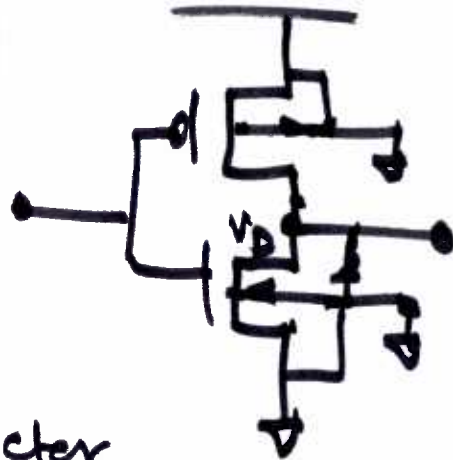


Bipolar
lateral Transistor

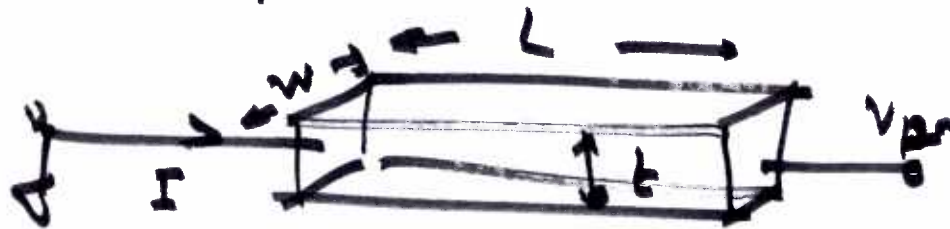


$R = 40K$ (We want!.)
 Then

$$\frac{L}{W} = 200$$



Semiconductor Resistor



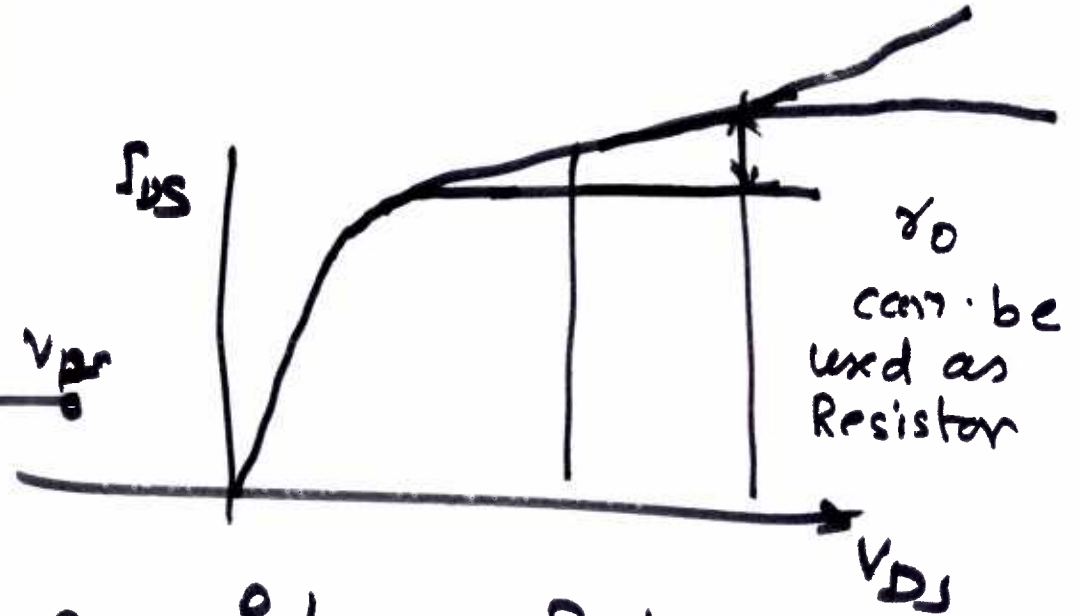
$$\frac{V}{I} = R$$

$$R = R_s \left(\frac{L}{W} \right)$$

If $R_s \rightarrow 200 \Omega/\square$



Meandered



$$R = \frac{\rho L}{A} = \frac{\rho \cdot L}{W \cdot t}$$

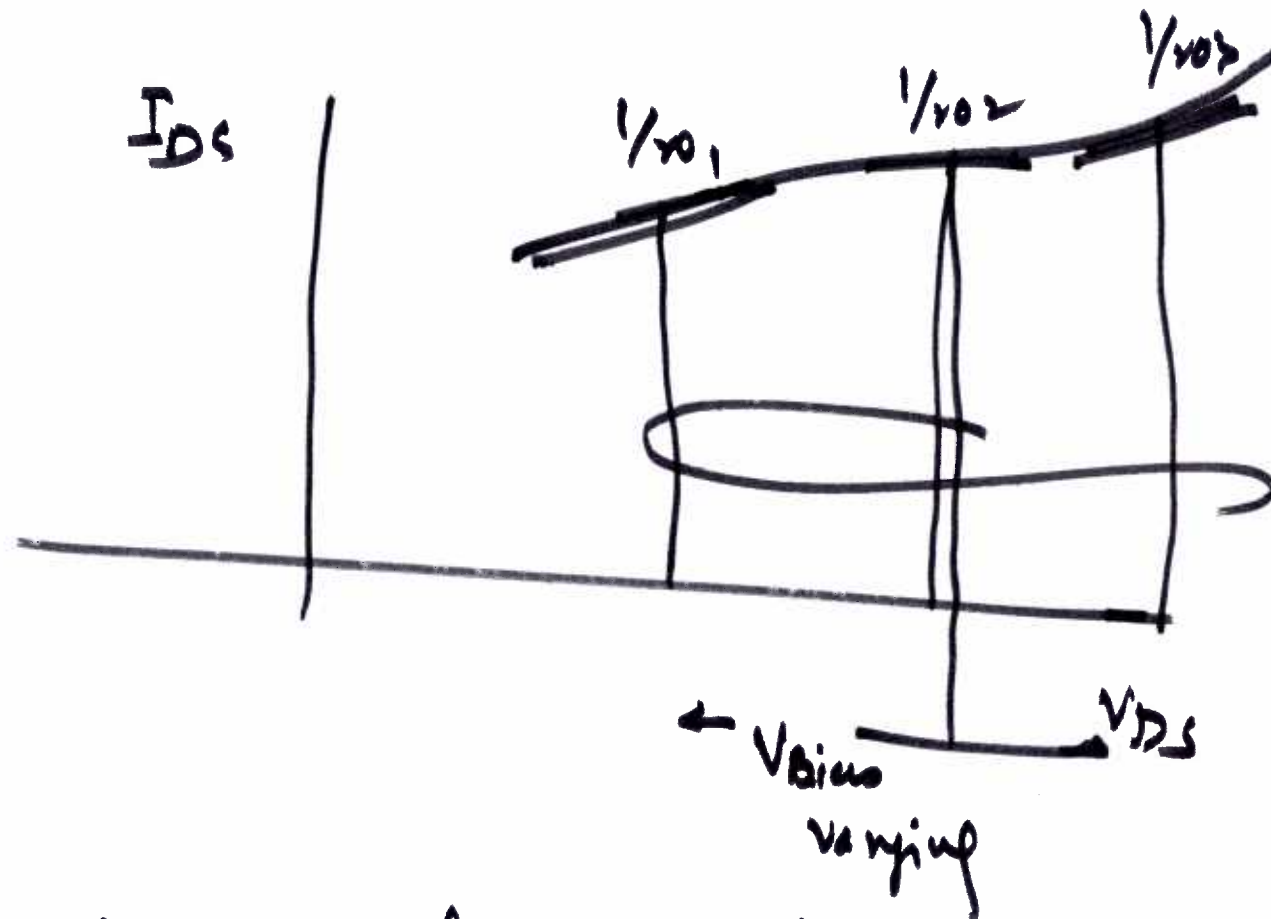
$$R_s = \text{Sheet Resistance} = \left(\frac{\rho}{t} \right)$$



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r_o is function of V_{DS} in Large Signal case



r_o is a function of V_{DS} if V_{DS} swing is high, or V_{Bias} is too low or too high.



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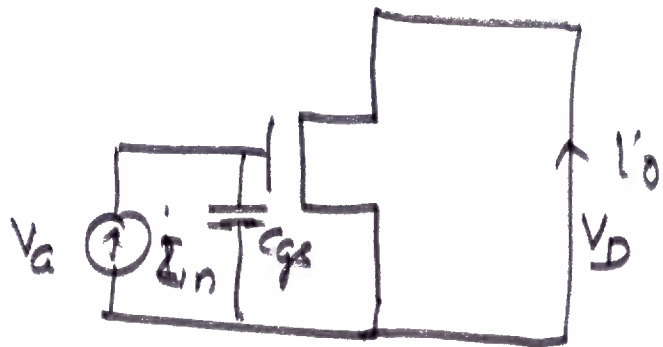
Concept of f_T (or ω_T)

f_T is a very standard Figure of Merit which is the frequency at which common source current gain i_o/i_{in} is UNITY.



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$$v_{gs} C_{gs} \omega = i_{in}$$

$$g_m v_{gs} = i_o$$

$$\therefore \frac{i_o}{i_{in}} = 1 = \frac{g_m}{\omega C_{gs}} = \frac{2}{2} \frac{\mu V_{ov}}{L^2} \cdot \frac{1}{\omega}$$

$$\text{or } \omega_T = 2\pi f_T = \frac{g_m}{C_{gs}} = \frac{3}{2} \frac{\mu V_{ov}}{L^2}$$

$$\therefore f_T = \frac{3}{2\pi} \left(\frac{\mu}{L^2} \right) V_{ov}$$

$$\approx 10 \text{ GHz}$$

Concept of ω_{max} .

Typically $\omega_{max} = \frac{\omega_T}{10}$ - Lumped Model Validation.

$$\omega_{max} = \frac{1}{2} \sqrt{\left(\frac{1}{R_a g_a}\right)} \omega_T$$



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In evaluation of f_T , we have used Long Channel Model for MOSFET.

Exptal Observations

1. f_T measured at large V_{ov} ,
In Weak Inversion and in V. Strong Inversion
Show lower values compared to theoretical
value.

Possible reason :

In Short Channel devices, g_m is lower at larger V_{ov} . It reduces g_m/I_{DS} term, as well as $f_T (= g_m/C_{gs})$. In Short Channel case Source-Sub-Drain forms a BJT which is stronger in Weak & Strong Inversion.



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In short channel devices, lateral fields and velocity saturation affect the g_m/I_{D_S}

It is known that approx. expressions which can be used in short channel devices based Analog Circuits are :-

$$I_{D_S} = \frac{1}{2} \mu C_{ox} \left(\frac{W}{L} \right) V_{OV}^2 \left(\frac{1}{1 + \frac{V_{OV}}{E_c \cdot L}} \right)$$

$$\cong \frac{1}{2} \mu C_{ox} \left(\frac{W}{L} \right) V_{OV} \left(\frac{E_c \cdot L \cdot V_{OV}}{E_c L + V_{OV}} \right)$$

Then $\frac{g_m}{I_{D_S}} = \frac{2}{V_{OV}} \cdot \frac{1}{1 + \frac{V_{OV}}{E_c \cdot L}}$

$$g_m/I_{D_S} = \left(\frac{2}{V_{OV}} \right) \underline{(0.9)} \frac{E_c \cdot L}{\leftarrow \text{correction factor}}$$



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Typical
 $E_c \cong 6 \times 10^6 \text{ V/cm.}$
for 0.25μ
 $= 1.5 \times 10^6 \text{ V/cm.}$
for 0.13μ .

For $E_c L = 2 \text{ V}$ & $V_{OV} = 0.2 \text{ V}$